

Announcement

INTERNATIONAL SOCIETY FOR HYBRID MICROELECTRONICS

The International Society for Hybrid Microelectronics is based in the U.S.A., and there are independent parallel organisations throughout the world. These groups are independent, non-profitmaking organisations, the purpose of which is to provide an informal means of discussing and advancing hybrid technology. This is achieved by the organisation of meetings, the publication of a Newsletter and other activities as appropriate. Membership is open to all and there are no formal entry requirements.

All these societies run a programme of meetings throughout the year on subjects concerned with thick films, and interested readers are advised to contact the following Chairmen for details of meetings in their own areas:

1. Benelux

Mr G. K. Steenvoorden
Technische Hogeschool Delft
Lorentzweg 1
NL.2628 C. J. DELFT
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2. France

Dr B. Dreyfus-Alain
President de I.F.M.H.
114 Rue de Damiette
91190 GIF SUR YVETTE, France

3. Germany

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Chairman I.S.H.M. Deutschland
Reinekestrasse 22
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W. Germany

4. Italy

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Italy

5. Japan

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292 Yoshida-Cho
Totsuka-ku,
YOKOHAMA,
Japan.

6. Nordic

Mr E. Järvinen
Technical Research Centre of Finland
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Finland

7. U.K.

Dr J. T. Law
Bio-engineering Unit
Princess Margaret Rose Hospital
Fairmile Head
EDINBURGH
Scotland
Great Britain

8. U.S.A. — all U.S. Chapters

I.S.H.M.
P.O. Box 3255
MONTGOMERY
Alabama 36109, U.S.A.

In addition, the European Chapters are all linked together through the European Liaison Committee, Chairman:

Prof. R. Govaerts,
Instituut Elektrotechniek,
K. U. Leuven,
Kardinal Mercierlaan 94,
B-3030 HEVERLEE, Belgium.



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